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In re Application of:

Gurtej S. Sandhu

Serial No.: 09/023,146

Filed: February 12, 1998

For: TUNGSTEN SILICIDE (WSIx)  
DEPOSITION PROCESS FOR  
SEMICONDUCTOR MANUFACTURE

Examiner: T. Dang

Group Art Unit: 2823

Attorney Docket No.: 3369.1US  
(91-365RE)

NOTICE OF EXPRESS MAILING

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REMARKS UNDER 37 C.F.R. §1.116

Box AF  
Commissioner for Patents  
Washington, D.C. 20231

Sir:

The following remarks are filed in response to the Examiner's remarks in the Final Office Action mailed October 23, 2001, the three-month shortened statutory period for response to which expires on January 23, 2002. This response is submitted on or before December 23, 2001, two months from the mailing date of the Final Office Action.